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PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

if re application of

Docket No: Q54388

Atsushi SAKAI, et al.

Appln. No.: 09/576,957

Group Art Unit: 2822

Confirmation No.: 5486

Examiner: Michael Manh Trinh

Filed: May 24, 2000

For: SOLID ELECTROLYTIC CAPACITOR AND METHOD FOR PRODUCING THE SAME

## AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents Washington, D.C. 20231

Sir:

This Amendment is submitted in response to the Office Action dated August 14, 2002, in which the Examiner set a three-month period for response. Review and reconsideration on the merits in view of the following remarks and amendments is respectfully requested.

Please amend the above-identified application as follows:

## IN THE CLAIMS:

## Please enter the following amended claims:

1. (Twice Amended) A method for producing a solid electrolytic capacitor comprising a metal material having thereon a dielectric film having surface pores and a solid electrolyte formed on a desired position of the dielectric film, the metal material having valve action, wherein the method comprises the step of coating by presscontacting a masking material solution that infiltrates into the pores of the dielectric film and forms a masking layer on the infiltrated portion and linearly around an entire circumference of the metal material.

